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Aug 31, 2008 9780815515548 Handbook of silicon wafer cleaning technology, 2d ed. Ed. by Karen Reinhardt and Werner Kern. William Andrew Publishing

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Sep 5, 2011 The temperature of the Si clean surface preparation, the final Reinhardt KA, Kern W, (Eds): Handbook of silicon wafer cleaning technology.

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Jul 9, 2013 SPIE 8786, Pacific Rim Laser Damage 2013: Optical Materials for chemical surface cleaning and optimized HF-based etch process. of optical glass", Applied Surface Science 253, 4951-4954 (2007) Karen A. Reinhardt, Werner Kern, "Handbook of silicon wafer cleaning technology 2nd edition", ISBN

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Bibliography -

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